



Last Time

Force balance model for CHF

Statistical approach for CHF

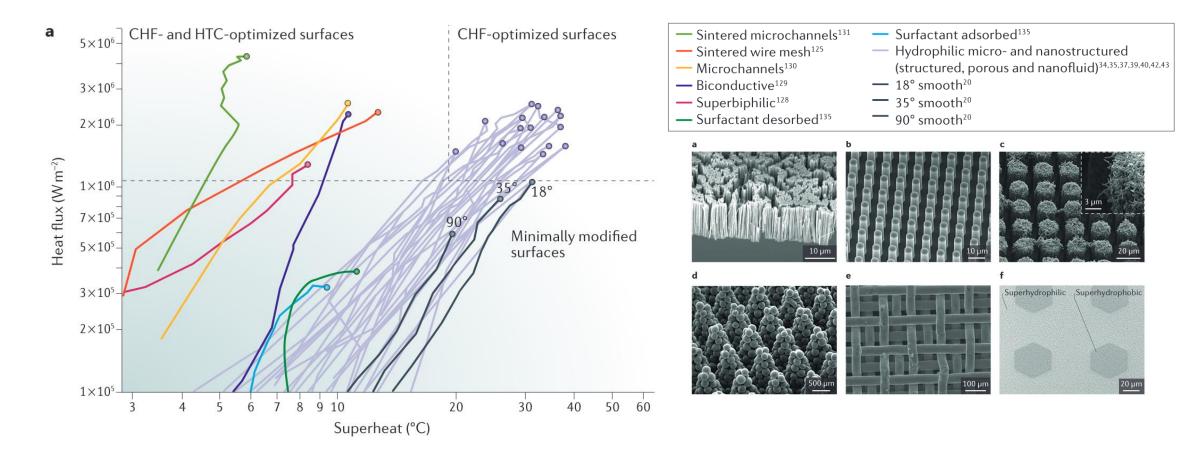


Statistical Approach for CHF

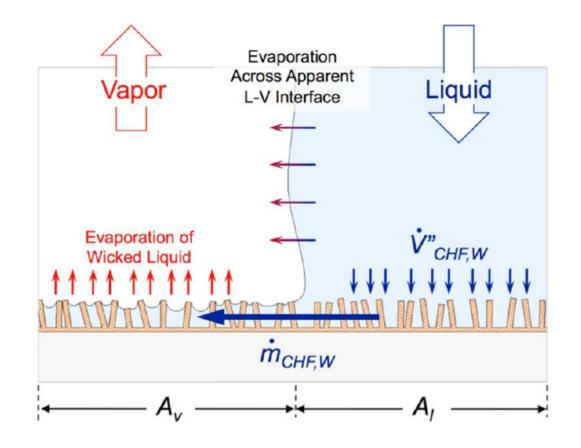
- Isolated bubbles dissipate heat better than merged bubbles
- With elevated temperature, more nucleation sites become activated while more bubbles are likely to merge into each other.
- We consider the probability of having N bubbles on the surface and the probability distribution of nearest neighbor distance
- CHF is reached when you have the maximum number of isolated bubbles



Surface Engineering for Boiling Enhancement



Wicking Helps Boiling

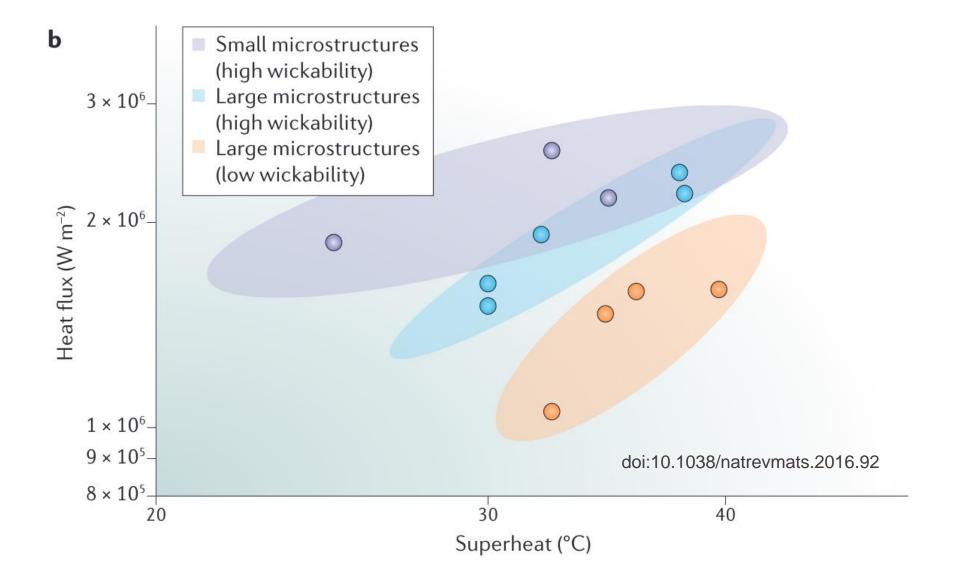




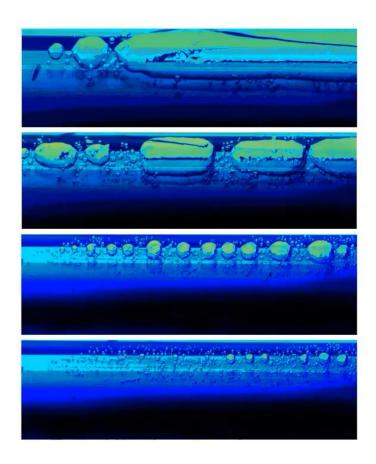
https://doi.org/10.1021/la5030923

https://doi.org/10.1021/acs.langmuir.7b01522

Wickability Helps Boiling



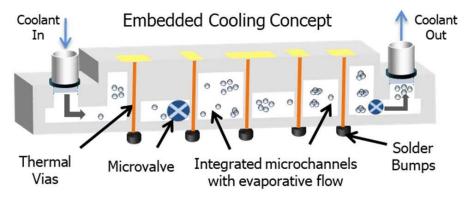
Intro to Flow Boiling



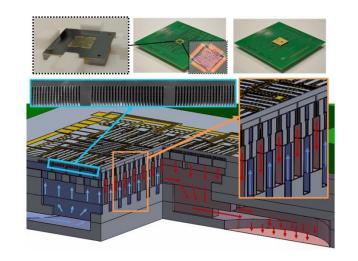
Different regimes in flow boiling (slowed down 50 times)

https://www.youtube.com/shorts/HNcp7zDtwx8?feature=share

Primarily explored for high flux electronics cooling



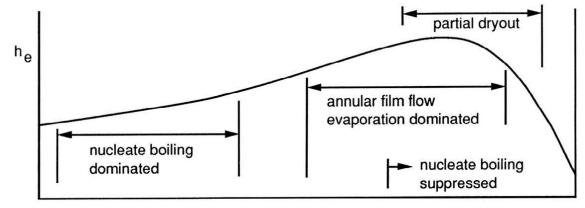
DOI: 10.1109/TCPMT.2021.3111114



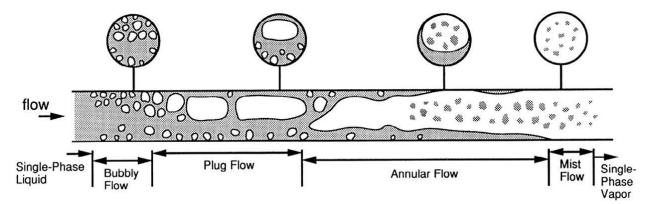
International Journal of Heat and Mass Transfer 117 (2018) 319–330

Flow Regimes

Figure 12.1 in Carey



distance along passage -increasing quality --



Bubbly flow: discrete bubbles dispersed in continuous liquid phase

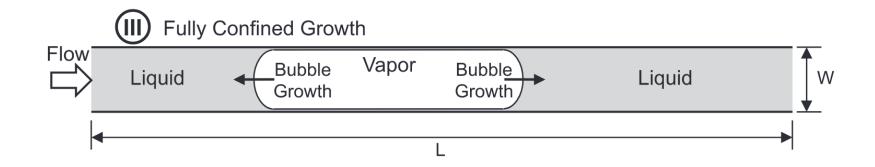
Plug flow: coalescence of small bubbles produces large bubbles flowing in the upper portion

Annular flow: most liquid flowing along the wall and gas flowing in the central core

Mist flow: discrete droplets dispersed in continuous vapor phase



Oscillations in Microchannel Flow Boiling



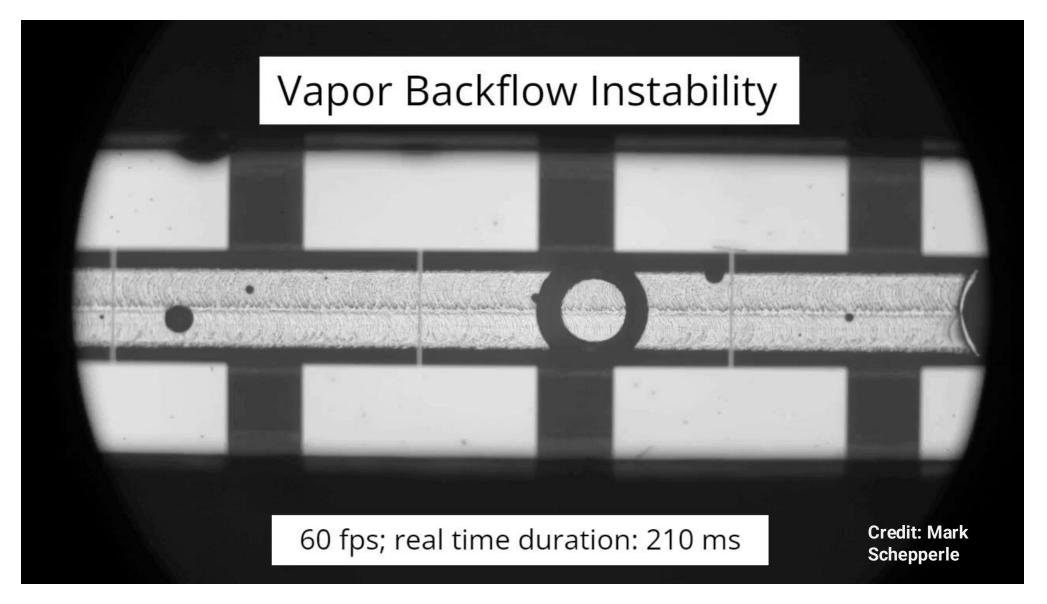
Bubble expansion toward the inlet causing density wave oscillation in microchannels

Flow rate reduced (potentially leading to backflow), which gives rise to further vapor expansion toward the inlet

Eventually, liquid rushes back into the channel when sufficient pressure is built up



Density Wave Oscillations in Microchannels



Gas Evolving Reaction



Industrial electrochemical processes that involves bubbles

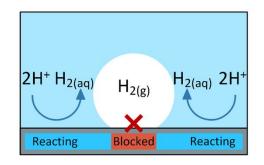
Water splitting

Aluminum production

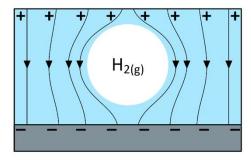
Sodium chlorate production

Chlorine and sodium hydroxide production

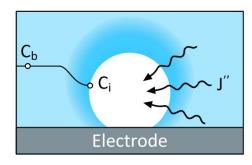
Effect of Bubbles on Electrochemical Reactions



Blocking reaction area

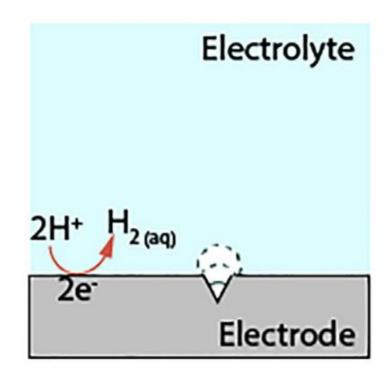


Additional resistance for ion transport



Additional diffusion resistance Bubble-induced convection

Nucleation



https://doi.org/10.1016/j.joule.2020.01.005

Equilibrium saturation concentration of dissolved gas in liquid is governed by Henry's law

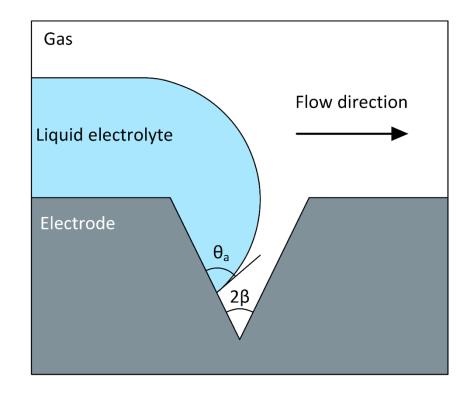
$$C_{sat} = PK_H(T)$$

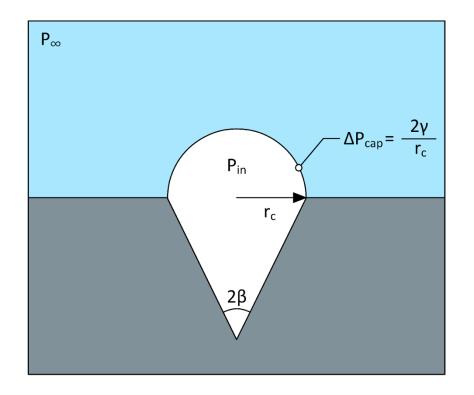
P: partial pressure of the gas acting on a liquid

 K_H : Henry's solubility constant (decreasing with T)

In electrochemical processes, nucleation takes place when concentration of dissolved gas becomes much larger than saturation values

Entrapped Gas Theory





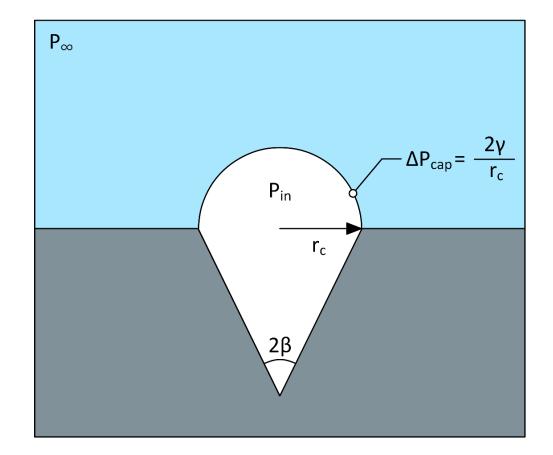
Surface cavity can cause gas-entrapping to facilitate nucleation

On hydrophilic surfaces: critical pressure $P_{in} = P_{\infty} + \frac{2\gamma}{r_c}$

$$P_{in} = P_{\infty} + \frac{2\gamma}{r_c}$$



Critical Surface Gas Concentration



Far field saturation concentration

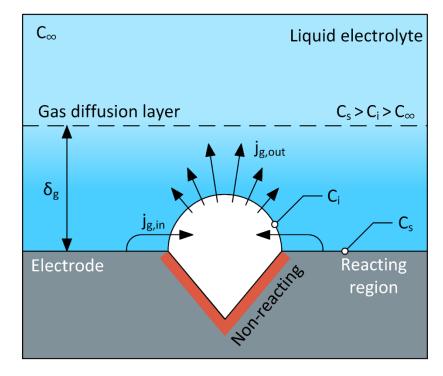
$$C_{\infty} = K_H P_{\infty}$$

Interface saturation concentration

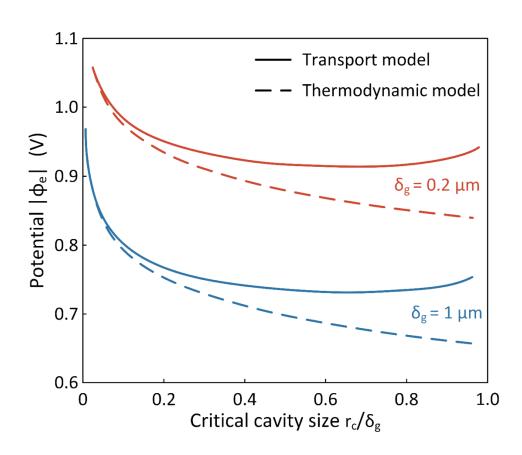
$$C_S = K_H \left(P_{\infty} + \frac{2\gamma}{r_c} \right) = C_{\infty} \left(1 + \frac{2\gamma}{r_c P_{\infty}} \right)$$

For
$$r_c = 10$$
 nm, $C_s/C_{\infty} \sim 100$

Transport Based Model



https://doi.org/10.1021/acs.langmuir.0c02690

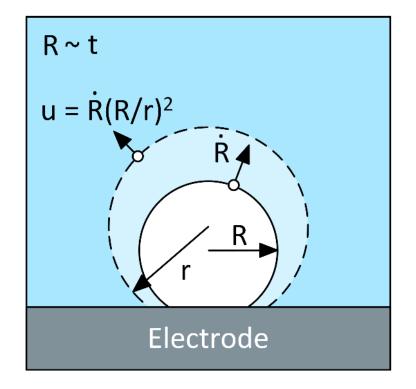


The presence of bubble will impact how the gas is supplied to the bubble

When cavity is too large, the outgassing to the far field can collapse the bubble even when the gas is supersaturated at the electrode

Bubble Growth

• First stage: inertial-controlled growth



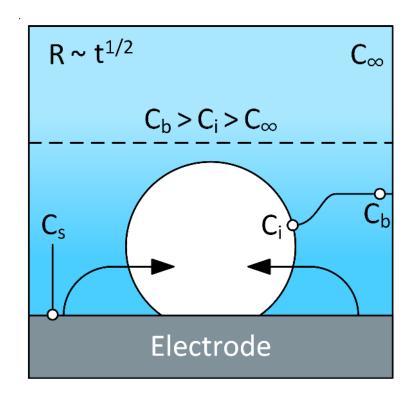
Balancing the kinetic energy of the flow field and the total work exerted from the pressure driven bubble expansion

$$R \sim t$$

Rayleigh—Plesset equation (similar to the boiling case)

Bubble Growth

Second stage: diffusion-controlled growth



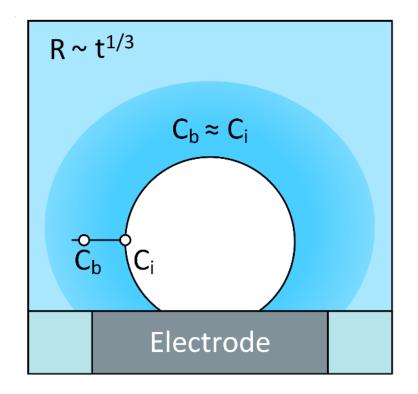
Bubble growth dictated by gas diffusion from the electrode to liquid-gas interface

$$R \sim \sqrt{t}$$

In boiling, this corresponds to thermal conduction from heated surface to liquid-vapor interface

Bubble Growth

Third stage: reaction-controlled growth

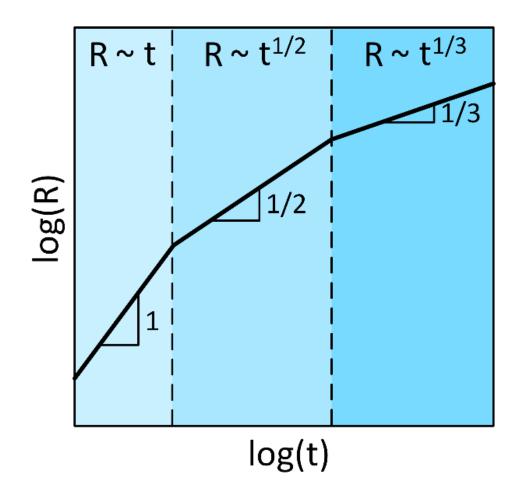


Rate of bubble volumetric increase is ultimately proportional to the total electrochemical reaction rate over the entire electrode surface

When bubble size is comparable to the electrode size,

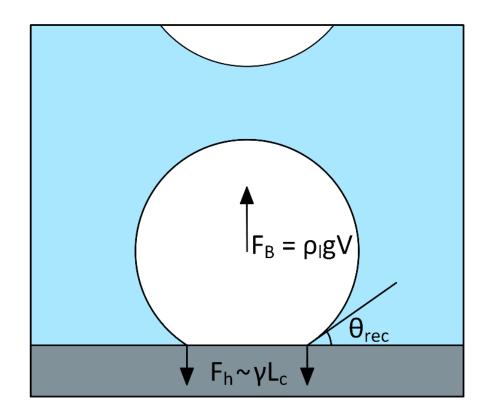
$$R \sim t^{1/3}$$

Bubble Growth





Bubble Departure

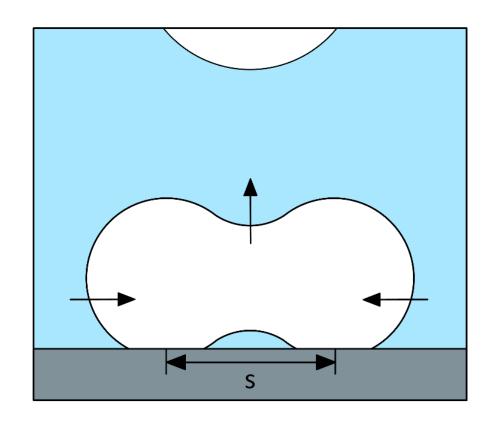


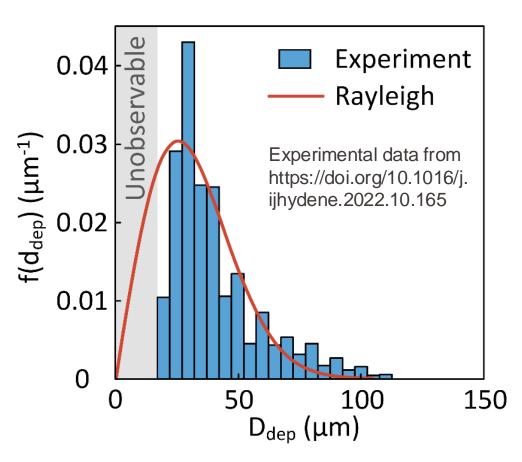
Fritz expression for bubble departure

$$Bo_d^{1/2} = 0.0208\theta$$

$$Bo_d = \frac{(\rho_l - \rho_v)d^2g}{\sigma_{lv}}$$

Coalescence-Driven Departure





When two bubbles coalesce into one, volume is roughly consumed, but surface area becomes smaller. Excess surface energy needs to be released.